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A facile and catalytic method for selective deprotection of *tert*-butyldimethylsilyl ethers with copper(II) bromide

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Abstract—Copper(II) bromide is found to be a simple and efficient catalyst for selective deprotection of *tert*-butyldimethylsilyl ethers of alcohols/phenols at ambient temperature. Various labile functional groups such as ketal, alkene, ketone, OTBDPS, OTHP and allyl and benzyl ethers are found to be compatible under the reaction conditions. © 2006 Elsevier Ltd. All rights reserved.

The challenge of synthesizing complex synthetic targets necessitates the continued use of protection/deprotection strategies in synthetic organic chemistry. The ability to efficiently protect, and then deprotect hydroxyl groups has become very important due to the abundance of multiple oxygenated functionalities in various natural product targets.¹ Among different functional groups, the protection of a hydroxyl group as a tertbutyldimethylsilyl (TBDMS) ether, a process developed by Corey et al.,² has occupied a prominent place in synthetic organic chemistry because it can be installed in high yields and is stable towards basic and mildly acidic conditions. Although tetra-n-butylammonium fluoride is the most common reagent for the cleavage of TBDMS ethers,² the strong basicity of the fluoride anion makes it inappropriate for base sensitive functionalities. Similarly, acidic reagents such as HCl,³ H₂SO₄,⁴ PPTS,⁵ TFA,⁶ TsOH,⁷ etc., have also been employed for this purpose but which cannot be used in the presence of acid-sensitive functionalities. This has led to the development of several Lewis acids and other reagents including BF₃–OEt₂,⁸ BCl₃,⁹ Sc(OTf)₃,¹⁰ Ce(OTf)₄,¹¹ InCl₃,¹² ZnBr₂,¹³ Zn(BF₄)₂,¹⁴ CeCl₃–NaI,¹⁵ BiBr₃,¹⁶ BiOClO₄,¹⁷ Cs₂CO₃,¹⁸ CBr₄–MeOH,¹⁹ I₂²⁰ and CAN²¹ for desilylation. However, many of these methods involve acidic, basic, reducing/oxidizing or high temperature reaction conditions that limit their scope. Thus, there is still a need to develop new reagents in order to remove the TBDMS group selectively, under mild conditions, without affecting other sensitive groups. Recently, we demonstrated that copper(II) bromide (CuBr₂) can catalyze the imino Diels–Alder reaction²² and alkylations of indoles.²³ We investigated the use of this inexpensive reagent in the deprotection of TBDMS ethers (Scheme 1) and report our findings herein.

Initially, the TBDMS ether of cetyl alcohol 1 was subjected to desilylation with 10 mol % of CuBr₂ in acetonitrile at room temperature. To our satisfaction, deprotection was observed to yield cetyl alcohol in 50% yield along with unreacted 1 (40%) (Table 1, entry 1). Encouraged by this result, the reaction parameters including solvent, reaction temperature and catalyst concentration were optimized (entries 2-8). Moreover, alumina supported CuBr₂, which has been reported earlier as a superior reagent for nuclear bromination of polyalkylbenzenes,²⁴ was also screened for desilylation (entries 9 and 10). The best result was obtained with 30 mol % of CuBr₂ in acetonitrile at room temperature (3 h) to yield cetyl alcohol in 86% yield (entry 2), and therefore the same conditions were used for all subsequent reactions. The exact mechanism of the deprotection with CuBr₂ is not clear to us at present.

Although a number of methods are available in the literature for the cleavage of alkyl TBDMS ethers, there

D OTDDMC	CuBr ₂ (30 mol%)	R-OH	
K-OTDDW5	MeCN rt	67 1000	
R = alkyl, aryl	wicciv, it	07-100%	

Scheme 1.

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Table 1. Effect of solvent, reagent and temperature on the $CuBr_2$ catalyzed deprotection of the TBDMS ether of cetyl alcohol 1

]	Entry	Solvent	Reagent and conditions ^a	Yield (%)
1	l	MeCN	CuBr ₂ (10 mol %), rt	50 ^b
2	2	MeCN	CuBr ₂ (30 mol %), rt	86
3	3	MeCN	$CuBr_2$ (30 mol %), Δ	51
2	1	CHCl ₃	CuBr ₂ (30 mol %), rt	35 ^b
4	5	THF	CuBr ₂ (30 mol %), rt	62
6	5	EtOAc	CuBr ₂ (30 mol %), rt	0
7	7	Dioxane	CuBr ₂ (30 mol %), rt	31 ^b
8	3	MeOH	CuBr ₂ (30 mol %), rt	83
9)	MeCN	Al ₂ O ₃ /CuBr ₂ (30 mol %), rt	39 ^b
1	0	CCl ₄	Al ₂ O ₃ /CuBr ₂ (30 mol %), rt	75

^a All the reactions were run for 16 h except for entries 2, 3 and 8 where the reactions were complete in 3 h.

^b 40–54% of 1 was recovered.

are only a few methods reported for the deprotection of phenolic TBDMS ethers.²⁵ Most of these methods use basic reagents and require elevated temperatures. Consequently, we studied the potential of CuBr₂ for the

deprotection of phenolic TBDMS ethers. Gratifyingly, a wide range of structurally varied phenolic TBDMS ethers 2–7, possessing both electron-donating or accepting groups on the aromatic ring, underwent easy deprotection to yield the corresponding phenols in good to excellent yields (Table 2, entries 1-6). It was of interest to determine whether mono-deprotection of a symmetric aromatic di-TBDMS ether substrate could be accomplished. Gratifyingly, with 5 mol % of the catalyst, (E)-1,2-bis(4-*tert*-butyldimethylsilyloxyphenyl)ethene 8 gave (*E*)-1-(4-*tert*-butyldimethylsilyloxyphenyl)-2-(4-hydroxyphenyl)ethene 9 in 48% yield along with 8(41%) (entry 7) while double deprotection was observed to afford 10 in quantitative yield with 10 mol % of the catalyst (entry 8). Similarly, (E)-1,2-bis(3-tert-butyldimethylsilyloxyphenyl)ethene 11 yielded (E)-1,2-bis(3-hydroxyphenyl)ethene 12 using 15 mol % of CuBr₂ (entry 9). Thus, in contrast to conventional methods for the deprotection of phenolic silyl ethers with basic reagents,²⁵ the present method allows deprotection of phenolic TBDMS ethers under practically neutral conditions.

Table 2. CuBr₂-catalyzed deprotection of aryl-TBDMS ethers in acetonitrile



^a Yields refer to pure isolated product.

^b 41% of **8** was recovered.

The utility of this method was further realized in the chemoselective cleavage of TBDMS ethers in the presence of other functionalities. Although, CuBr₂ is used for dibromination of alkenes²⁶ and α -bromination of carbonyl compounds,²⁷ the TBDMS ethers of 2-allylphenol 13 and homoallylic alcohol 14 underwent smooth deprotection to provide the corresponding alcohols without affecting the double bond (Table 3, entries 1 and 2). Also, for a more complex substrate 15, having a sensitive ketal and double bond functionalities, the TBDMS ether could be cleaved selectively, in good vield, without affecting the other functionalities (entry 3). Similarly, 4-tert-butyldimethyl silyloxyacetophenone 16 underwent easy deprotection to yield 4-hydroxyacetophenone (entry 4) without any evidence of bromination of the acetyl group.

Chemoselective deprotection of a TBDMS ether in the presence of other frequently used protected hydroxyl functions such as allyloxy, benzyloxy and tetrahydropyranyloxy was also achieved with high efficiency (Table 3, entries 5–7). Moreover, selective deprotection of a TBDMS ether in the presence of a TBDPS ether as in 5-(*tert*-butyldiphenylsilyloxy)pentan-1-ol TBDMS ether **17** was achieved to afford 5-(*tert*-butyldiphenylsilyloxy)pentan-1-ol **18** as the major product (60%) along with a small amount (8%) of 1,5-pentanediol using 30 mol % of the catalyst (entry 8).

Finally, selective deprotection of an aryl-TBDMS ether in the presence of an alkyl-TBDMS ether was investigated. Thus, reaction of 4-(*tert*-butyldimethylsilyloxymethyl)phenol TBDMS ether **19** with 30 mol % CuBr₂

Table 3. $CuBr_2$ catalyzed chemoselective deprotection of TBDMS ethers

Entry	Substrate	CuBr ₂ (mol %)	Time (h)	Product	Yield ^a (%)
1	OTBDMS	30	3	OH	77
2	13 OTBDMS 14	30	5	OH OH	82
3	OTBDMS	30	3		88
	syn and anti 15			syn and anti	
4	меос	30	24	МеОС-ОН	79
5	AllyIO	30	1.5	AllylO	88
6	BnOOTBDMS	30	2	BnOOOH	86
7	THPOOTBDMS	30	2	тнро Он но Отволмя	54
	TBDPSOOTBDMS			ТВДРЅО ОН	13
8	17	30	24	18	60 8
9	TBDMSO	10	24	TBDMSO OTBDMS	59
	19			но 21	17

^a Yields refer to pure isolated product.

yielded 4-(*tert*-butyldimethylsilyloxymethyl)phenol **20** in 59% yield as the major product along with a small amount (17%) of 4-*tert*-butyldimethylsilyloxy benzyl alcohol **21** (the NMR data of which was identical with that obtained from the NaBH₄ reduction of 4-*tert*-butyl-dimethylsilyloxybenzaldehyde) (entry 9). This clearly indicates that deprotection of aryl-TBDMS ethers is faster than that of alkyl-TBDMS ethers with CuBr₂.

In conclusion, $CuBr_2$ has been demonstrated to be a convenient deprotecting reagent for TBDMS ethers of alcohols/phenols. The advantages of the method are: (i) the use of a catalytic amount of an inexpensive reagent, (ii) simple experimental procedure, (iii) high chemoselectivity in the presence of ketal, allyl, benzyl, TBDPS and THP ethers and alkene functionalities and (iv) selectivity towards aryl-TBDMS ethers in the presence of aliphatic ones. These facets are very useful in complex multistep synthesis, which requires the sequential protection and deprotection of various functionalities.

Typical experimental procedure: A solution of a TBDMS ether of alcohol/phenol (2.0 mmol) and CuBr₂(0.6 mmol, 0.135 g, 30 mol %) in dry acetonitrile (10 mL) was stirred at room temperature for the appropriate amount of time (Tables 2 and 3). After completion of the reaction, as indicated by TLC, the reaction mixture was concentrated, quenched with water and ethyl acetate (10 mL) and passed through a Celite bed. The Celite was washed with ethyl acetate (2×5 mL). The organic layer was washed with water and, brine and then dried (Na₂SO₄). Removal of the solvent followed by preparative thin layer chromatography afforded the respective alcohol/phenol.

All the products were characterized from their spectroscopic data (IR, ¹H, ¹³C NMR and MS). The data for known compounds are in good agreement with those reported. Spectroscopic and analytical data for selected compounds are provided.²⁸

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- 28. Spectral data of selected compounds: (E)-1,2-Bis(4-tertbutyldimethylsilyloxyphenyl)ethene 8: solid. Mp 69-70 °C, IR (KBr): v = 3064, 3028, 2956, 2930, 2886, 2858, 1598, 1489, 1281, 921, 830 cm⁻¹. ¹H NMR (200 MHz, CDCl₃): $\delta = 7.26$ (d, 4H, J = 8.5 Hz), 6.81 (s, 2H), 6.71 (d, 4H, J = 8.5 Hz), 0.89 (s, 18H), 0.11 (s, 12H). ¹³C NMR (50 MHz, CDCl₃): $\delta = 155.0$, 130.8, 127.3, 123.3, 120.3, 25.7, 18.2, 4.4. MS (EI): m/z 441 (M + H⁺), 384, 326, 253, 162, 116, 72, 57. Anal Calcd for C₂₆H₄₀O₂Si₂: C 70.85, H 9.15. Found: C 70.68, H 9.01. (E)-1-(4-tert-Butyldimethylsilyloxyphenyl)-2-(4-hydroxyphenyl)ethene 9: solid. Mp 82–84 °C; IR (KBr): v = 3604, 3400, 3019, 2957, 2930, 2858, 1607, 1512, 1471, 1463, 1256, 1216, 1169, 911, 838, 758 cm⁻¹. ¹H NMR (200 MHz, CDCl₃): $\delta = 7.37$ (d, 4H, J = 8.0 Hz), 6.91 (s, 2H), 6.82 (m, 4H), 1.00 (s, 9 H), 0.22 (s, 6H). ¹³C NMR (50 MHz, CDCl₃): $\delta = 154.9$, 154.8, 130.9, 130.5, 127.5, 127.2, 126.1, 120.2, 115.5, 25.6, 18.1, 4.5. MS (EI): *m*/*z* 326 (M⁺), 213, 195, 165, 154, 118, 89. Anal. Calcd for C₂₀H₂₆O₂Si: C 73.57, H 8.03. Found: C 73.69, H 8.21. 4-(tert-Butyldimethylsilyloxy)-5,6-cyclo-

0.04 (s, 6H). ¹³C NMR (50 MHz, CDCl₃): δ = 134.9, 134.1, 117.4, 117.1, 109.7, 109.3, 78.3, 77.4, 73.3, 72.3, 66.0, 65.1, 39.3, 37.8, 36.7, 36.2, 34.9, 34.7, 25.8, 25.7, 25.2, 23.99, 23.8, 18.1, 18.0, -3.0, -4.2, -4.4, -4.6, -4.7. MS (EI): m/z 326 (M⁺), 286, 270, 212, 116, 100, 80, 73, 56.